## PATENT COOPERATION TREATY

# **PCT**

## INTERNATIONAL PRELIMINARY REPORT ON PATENTABILITY

(Chapter II of the Patent Cooperation Treaty)

(PCT Article 36 and Rule 70)

Applicant's or agent's file reference IPY-150		FOR FURTHER ACTION	N See Form PCT/IPEA/416				
Internation	onal application No.	International filing date (day)	y/month/year) Priority date (day/month/year)				
l		30.03.2004	31.03.2003				
Internation	International Patent Classification (IPC) or national classification and IPC						
Applicant UBE INDUSTRIES, LTD.							
1.	<ol> <li>This report is the international preliminary examination report, established by this International Preliminary Examining Authority under Article 35 and transmitted to the applicant according to Article 36.</li> </ol>						
2.	This REPORT consists of a total	of 10	sheets, including this cover sheet.				
3.	This report is also accompanied	by ANNEXES, comprising:					
	a. (sent to the applicant	and to the International Bureau) a	a total of 1 sheets, as follows:				
	sheets of the description, claims and/or drawings which have been amended and are the basis for this report and/or sheets containing rectifications authorized by this Authority (see Rule 70.16 and Section 607 of the Administrative Instructions).						
	sheets which supersede earlier sheets, but which this Authority considers contain an amendment that goes beyond the disclosure in the international application as filed, as indicated in item 4 of Box No. I and the Supplemental Box.						
	b. (sent to the International Bureau only) a total of (indicate type and number of electronic carrier(s))						
	o	mai Dar eda Oray, a total of (fildica	.,				
	related thereto, in com	puter readable form only, as indica	, containing a sequence listing and/or tables cated in the Supplemental Box Relating to Sequence Listing (see				
		ninistrative Instructions).					
4.	This report contains indications	relating to the following items:					
	Box No. I Basis of	of the report					
	Box No. II Priority	y					
	Box No. III Non-es	stablishment of opinion with regard	d to novelty, inventive step and industrial applicability				
	Box No. IV Lack of unity of invention						
	Box No. V  Reasoned statement under Article 35(2) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement						
	Box No. VI Certain documents cited						
	Box No. VII Certain	defects in the international applica	cation				
	Box No. VIII Certain	observations on the international	application				
Date of submission of the demand Date			of completion of this report				
Name and mailing address of the IPEA/JP			orized officer				
Facsimile No.			phone No.				

Translation

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Box	No. I	Basis of the report	
1.		regard to the language, this report is based on the internation ated under this item.	nal application in the language in which it was filed, unless otherwise
		This report is based on translations from the original language which is the language of a translation furnished for the purportion.	
		international search (Rule 12.3 and 23.1(b))	
		publication of the international application (Rule 12.4) international preliminary examination (Rule 55.2 and/o	
2.	With		report is based on (replacement sheets which have been furnished to the
		iving Office in response to an invitation under Article 14 are report):	referred to in this report as "originally filed" and are not annexed to
		the international application as originally filed/furnished	
	$\boxtimes$	the description:	
		pages 1-19	as originally filed/furnished
		pages*	received by this Authority on
		pages*	received by this Authority on
	$\boxtimes$	the claims:	
		nos. 1-8	as originally filed/furnished
		nos.*	as amended (together with any statement) under Article 19
		nos.* 9,11-14	received by this Authority on31.01.2005
		nos.*	received by this Authority on
	$\boxtimes$	the drawings:	
		sheets1/8-8/8	as originally filed/furnished
		sheets*	received by this Authority on
		sheets*	received by this Authority on
		a sequence listing and/or any related table(s) - see Supplem	ental Box Relating to Sequence Listing.
3.		The amendments have resulted in the cancellation of:	
		the description, pages	
		the claims, nos.	
		the drawings, sheets/figs	
		the sequence listing (specify):	
		any table(s) related to sequence listing (specify):	
4.	$\boxtimes$	This report has been established as if (some of) the amend they have been considered to go beyond the disclosure as file.	ments annexed to this report and listed below had not been made, since led, as indicated in the Supplemental Box (Rule 70.2(c)).
		the description, pages	
		the claims, nos. 10	
		the drawings, sheets/figs	
		the sequence listing (specify):	
		any table(s) related to sequence listing (specify):	
*	If ite	em 4 applies, some or all of those sheets may be marked "sup	erseded."

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Boz		Reasoned statement under Article 35(2) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement		
1.	Statement			
	Novelty (N)	Claims	1-9, 11-14	_ YES
		Claims		_ NO
	Inventive step (IS)	Claims		YES
		Claims	1-9, 11-14	_ NO
	Industrial applicability (IA)	Claims	1-9, 11-14	_ YES
		Claims		_ NO

#### 2. Citations and explanations (Rule 70.7)

- Document 1: JP 2003-017973 A (Murata Mfg. Co., Ltd.), 17

  January 2003, entire text and all drawings
- Document 2: JP 59-086916 A (Murata Mfg. Co., Ltd.), 19

  May 1984, page 2, lower right column, lines

  3 to 13, and fig. 3 and 4
- Document 3: JP 2001-004470 A (Hitachi, Ltd.), 12 January 2001, page 4, right column, lines 8 to 10 and all drawings

#### Claims 1 and 2

Claims 1 and 2 do not involve an inventive step in the light of document 1 and document 2 cited in the international search report.

Document 1 discloses the invention of a "piezoelectric thin film device that comprises a substrate, which has a vibration space, and a piezoelectric laminated structure, which has been formed upon the upper surface side of said substrate, wherein said piezoelectric laminated structure is configured from a piezoelectric film and electrodes that have been formed on both surfaces thereof while said vibration space is formed so as to allow the vibration of the vibrating part, which is configured in a manner such that it

Box No. V Reasoned statement under Article 35(2) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement

includes at least one portion of the aforementioned piezoelectric laminated structure; therein, said piezoelectric thin film is characterized in that the vibration space is configured from a first via hole, which has been formed towards the upper surface of the substrate from the lower surface of the substrate, and second via holes, which are formed towards the upper surface of the substrate at positions on the inside of the first via hole as viewed from the vertical direction." In addition, the technical feature of forming a vibration space that comprises an "intermediate surface" when creating a vibration space by means of a plurality of steps is well known, as disclosed in document 2.

Consequently, it would be easy for a person skilled in the art to conceive of forming the "intermediate surface" that is disclosed in document 2 in the invention that is disclosed in document 1.

Furthermore, the feature of forming a plurality of vibrating parts upon the upper surface side of a substrate is disclosed in document 1.

#### Claims 3 and 4

Claims 3 and 4 do not involve an inventive step in the light of document 1 and document 2 cited in the international search report.

Configuring the inventions that are disclosed in documents 1 and 2 so that "the second via holes are positioned at least 2  $\mu$ m to inside the first via hole" and the "depth of the via holes is between 10 to 150  $\mu$ m" is merely a design matter that could have been configured by a person skilled in the art in order to accommodate

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Box No. V Reasoned statement under Article 35(2) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement

the desired size of the element, the desired size of the vibration space and the like, as appropriate.

#### Claims 5 and 6

Claims 5 and 6 do not involve an inventive step in the light of document 1 and document 2 cited in the international search report.

The inventions set forth in claims 5 and 6 pertain to a method for producing the piezoelectric thin film device that is set forth in claims 1 and 2 by means of a conventional technique; therefore, it would have been easy for a person skilled in the art to conceive of the invention in question in the light of documents 1 and 2.

## Claim 7

Claim 7 does not involve an inventive step in the light of document 1 and document 2 cited in the international search report.

The feature of using a SOI wafer as the substrate material and then configuring the bottom surface of the first via hole from a portion of the insulating layer is disclosed in document 1.

#### Claim 8

Claim 8 does not involve an inventive step in the light of document 1, document 2 and document 3 cited in the international search report.

The technique for forming via holes by means of a deep reactive ion etching method is well known, as disclosed in document 3.

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Box No. V Reasoned statement under Article 35(2) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement

Claim 9

Claim 9 does not involve an inventive step in the light of document 1 and document 2 cited in the international search report.

Configuring the inventions that are disclosed in documents 1 and 2 so that the second via holes are "5 to 50  $\mu$ m" from the end part of the bottom surface of the first via hole is merely a design matter that could have been configured by a person skilled in the art in order to accommodate the desired size of the element, the desired size of the vibration space and the like, as appropriate.

#### Claims 11 and 14

Claims 11 and 14 do not involve an inventive step in the light of document 1 and document 2 cited in the international search report.

When producing a piezoelectric thin film device, the question of whether the level of resonant frequency distribution for determining whether the article is nondefective should be set to a level of 'within  $\pm$  0.1%' or to a level of 'within  $\pm$  0.42%' is merely a design matter that could have been configured by a person skilled in the art in order to accommodate the desired degree of design precision, as appropriate.

#### Claims 12 and 13

Claims 12 and 13 do not involve an inventive step in the light of document 1 and document 2 cited in the international search report.

When forming a pattern by means of photolithography, the question of whether to delimit a

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Box No. V Reasoned statement under Article 35(2) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement				
range of "0.5 to 4.0 μm" for the thickness of the				
photoresist is merely a design matter that could have				
been configured by a person skilled in the art, as				
appropriate.				

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Box No. VIII Certain observations on the international application

The following observations on the clarity of the claims, description, and drawings or on the question whether the claims are fully supported by the description, are made:

#### Claims 3 and 12

Claims 3 and 12 set forth a feature wherein the second via hole is positioned "2  $\mu m$  or less" [to the inside of] the first via hole. However, the assertion that it is possible to achieve a desired effect by configuring so that the distance is "2  $\mu m$  or less" as opposed to 5  $\mu m$  or 2.1  $\mu m$  is not fully supported by the description.

#### Claims 4 and 13

Claims 4 and 13 set forth a feature wherein the depth of the second via hole is "10 to 150  $\mu$ m." However, the assertion that it is possible to achieve a desired effect by configuring so that the depth is "10 to 150  $\mu$ m" as opposed to 9  $\mu$ m or 151  $\mu$ m is not fully supported by the description.

#### Claim 9

Claim 9 sets forth a feature wherein the second via hole is positioned so as to be separated by a distance of "5 to 50  $\mu$ m" from the end part of the bottom surface of the first via hole. However, the assertion that it is possible to achieve a desired effect by configuring so that the distance is "5 to 50  $\mu$ m" as opposed to 4  $\mu$ m or 51  $\mu$ m is not fully supported by the description.

#### Claims 11 and 14

Claims 11 and 14 set forth a feature wherein the resonance frequency distribution is set to "within  $\pm$  0.42%." However, the assertion that it is possible to

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Box No. VIII Certain observations on the international application				
achieve a desired effect by configuring so that the				
resonance frequency distribution is "withi	in ± 0.42%" as			
opposed to within $\pm$ 0.43% or within $\pm$ 0.54	4% is not fully			
supported by the description.				
·				

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Supplemental Box

In case the space in any of the preceding boxes is not sufficient. Continuation of:

Box. I

The amendment to claim 10, which delimits a numerical range of "0.3  $\mu m$  to 0.5  $\mu m$ " for the thickness of the insulating layer, goes beyond the scope of the disclosure in the international application as originally filed.